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IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF

MASAYUKI ISHIKAWA ET AL

ALLOWED: MARCH 4, 2005

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EXAMINER: IGWE U. ANYA

FILED: APRIL 5, 2004

ART UNIT: 2829

FOR: SEMICONDUCTOR DEVICE,
SEMICONDUCTOR LASER, THEIR
MANUFACTURING METHODS AD
ETCHING METHODS

AMENDMENT UNDER 37 CFR §1.312

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

Prior to issuance, please amend the above-identified divisional application as follows:

Amendments to the Claims begin on page 2 of this paper.

Remarks/Arguments begin on page 5 of this paper.